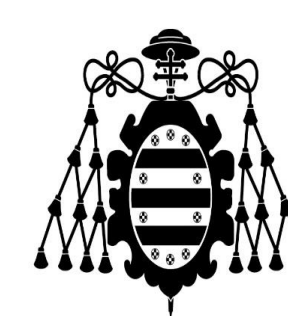


## Optical Characterization of Nanoporous Alumina-based Structures Modified by ALD Technique



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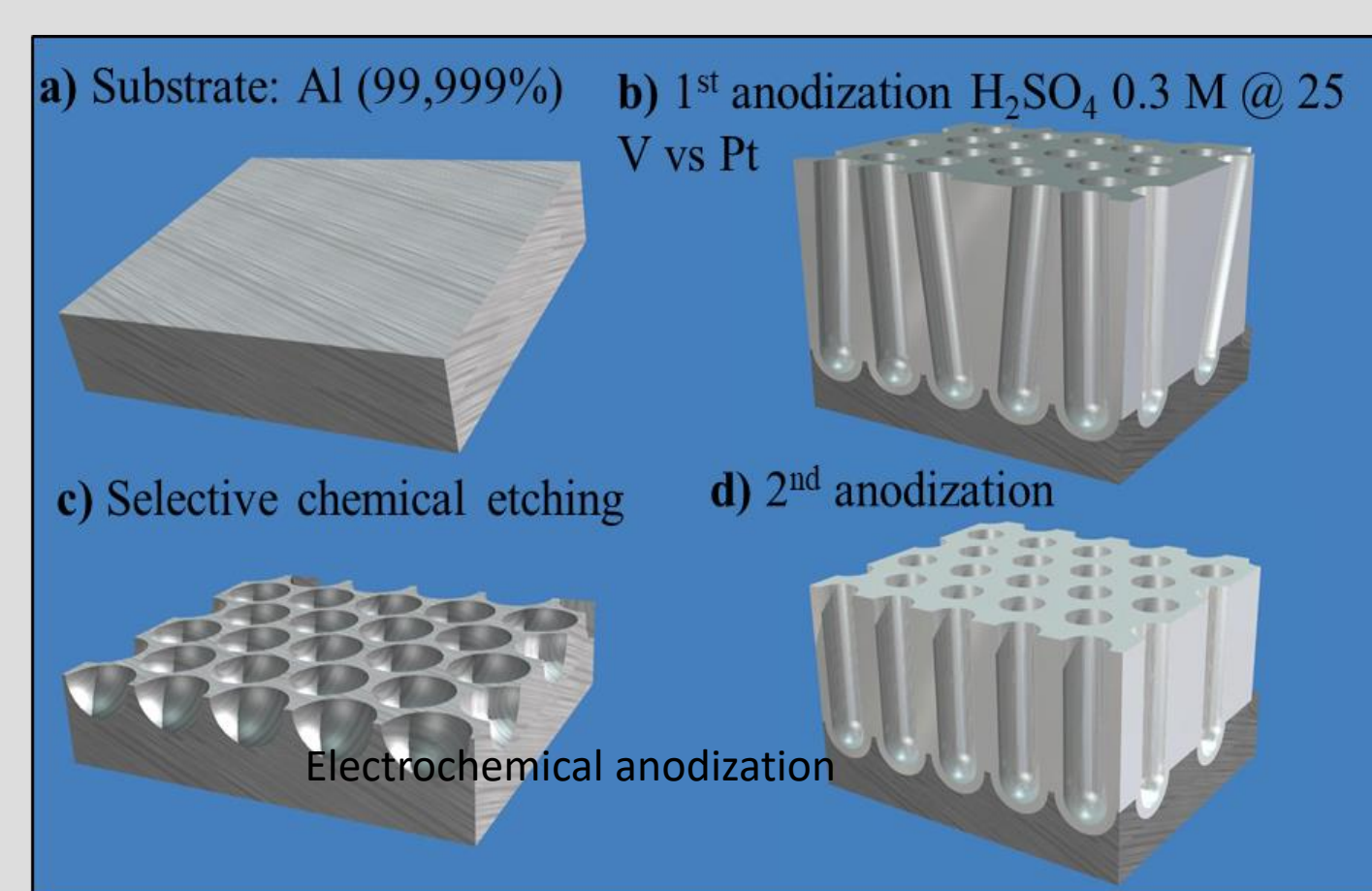
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Nanoporous alumina structures (NPASs) obtained by the two-step anodization method exhibit well-defined morphology (parallel array of straight cylindrical nano-channels without practically pore radii dispersion), high surface area and aspect ratio, being of interest in nanotechnology (nano-templates, drug delivery, nanofilters, photonic crystals,...). Moreover, the possibility of easy surface material and pore radii walls modification by a well-established technique such as atomic layer deposition (ALD) makes of these new nanoporous alumina-based structures (NPA-bSs) excellent platforms for other applications (chemical, biological or optical sensors). In this work, we study optical changes in a NPAS as a result of its coverage by a layer of a metal oxide by ALD technique (NPAS+X samples). Different metal oxides (X = Al<sub>2</sub>O<sub>3</sub>, TiO<sub>2</sub>, Fe<sub>2</sub>O<sub>3</sub> or ZnO) were used as coating layer of these new nanoporous alumina-based structures (NPA-bSs) which maintain similar geometrical parameters; moreover, the effect of pore size/porosity for samples with the same surface material on light transmittance and refraction index is also considered.

- ✓ **Highly ordered nanoporous alumina structure** (NPAS) obtained by two-step anodization. Pore radius  $r_p = 12$  nm; porosity  $\Theta = 12$  %; Thickness 63  $\mu$ m.
- ✓ Surface modification by **ALD** (Savannah 100, CNT) of a functional oxides (Al<sub>2</sub>O<sub>3</sub>, Fe<sub>2</sub>O<sub>3</sub>, ZnO, TiO<sub>2</sub>)
- ✓ **Morphological characterization**: SEM micrographs of samples surfaces and image analysis ( $\Theta = (2\pi/3^{1/2})(r_p/D_{int})^2$ )
- ✓ **XPS analysis** (ESCA 5701) with a non-monochromatic MgK $\alpha$  radiation (300 W, 15 kV, 1253.6 eV) (Table 3, surface atomic concentration percentages (A.C. %). **Depth-profile XPS analysis** (Ar sputtering, 4 kV and 1.5 mA, 8 min). This sample-destructive process allows estimation of layers characteristics evolution (Fig. 3)
- ✓ **Transmittance spectra** (Varian Cary 5000 spectrophotometer, Agilent Technologies) with an integrating sphere (wavelength interval of 200-2000 nm).
- ✓ **Spectroscopic Ellipsometry** (SE) measurements were carried out with a spectroscopic ellipsometer (Sopra-Semilab GES-5E) and wavelength ranging from 400 nm to 1600 nm at an incident angle of 70°. WinElli software (Sopra-Semilab) was used for data analysis and fittings.

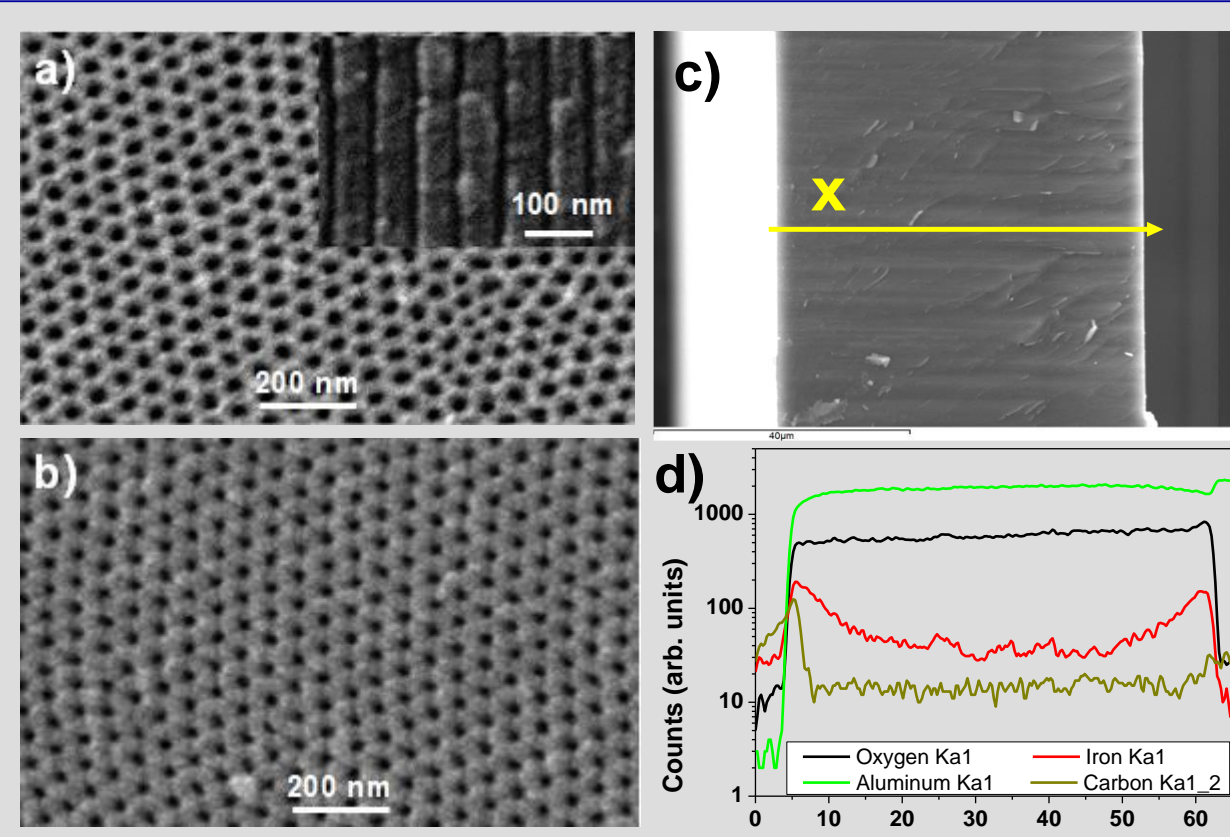
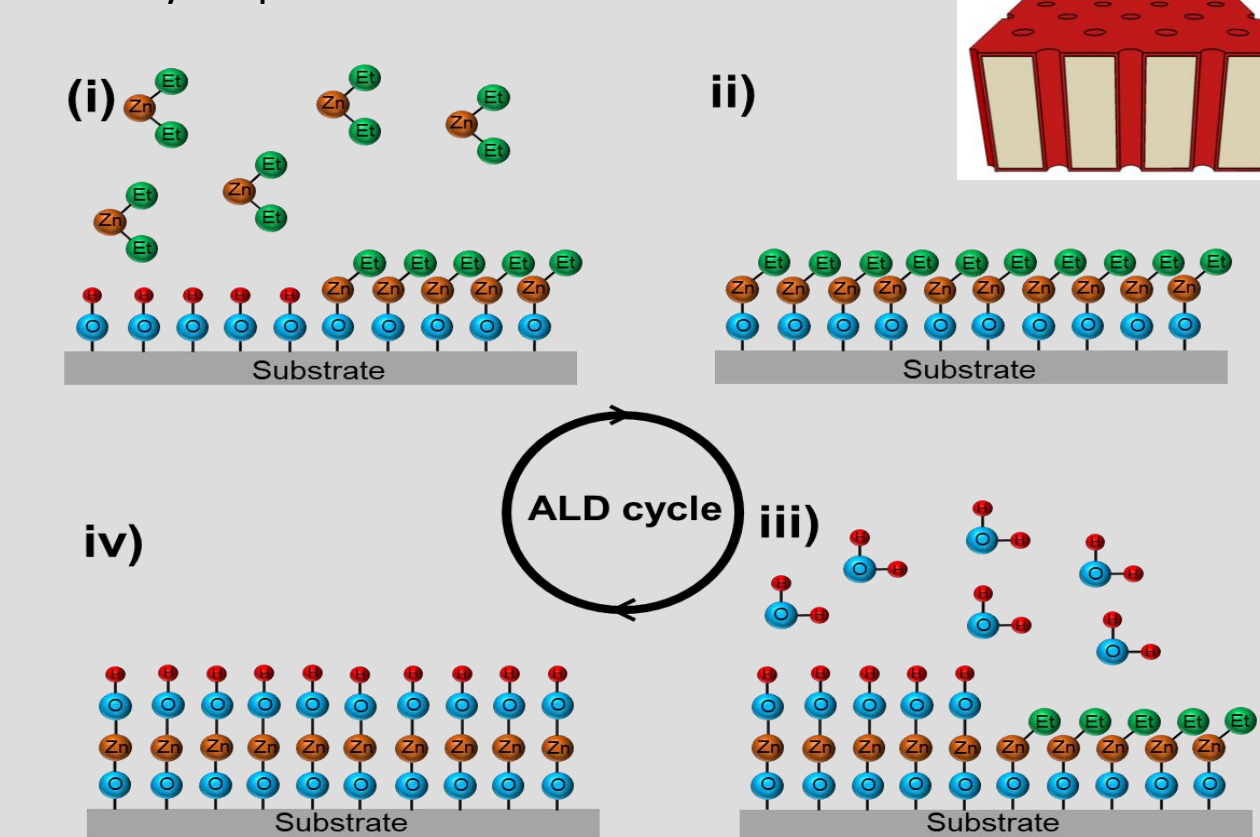


### Nanoporous alumina structures synthesis and ALD coating

ALD precursors & conditions

Oxide layer	ALD precursors	Precursor temperature (°C)	Substrate temperature (°C)
Al <sub>2</sub> O <sub>3</sub>	H <sub>2</sub> O Trimethylaluminum (C <sub>3</sub> H <sub>9</sub> Al <sub>3</sub> )	60 20	200
Fe <sub>2</sub> O <sub>3</sub>	O <sub>3</sub> Ferrocene (C <sub>10</sub> H <sub>10</sub> Fe)	20 100	230
ZnO	H <sub>2</sub> O Diethylzinc (C <sub>4</sub> H <sub>10</sub> Zn)	60 20	200
TiO <sub>2</sub>	H <sub>2</sub> O Titanium tetraisopropoxide (C <sub>12</sub> H <sub>28</sub> O <sub>4</sub> Ti)	60 75	200

ALD cyclic process



SEM images: (a) NPAS and (b) NPAS+ZnO  
(c) cross section and (d) EDX analysis

### Morphological and Chemical Characterizations

Average pore radius  $\langle r_p \rangle$  and porosity  $\Theta$ .

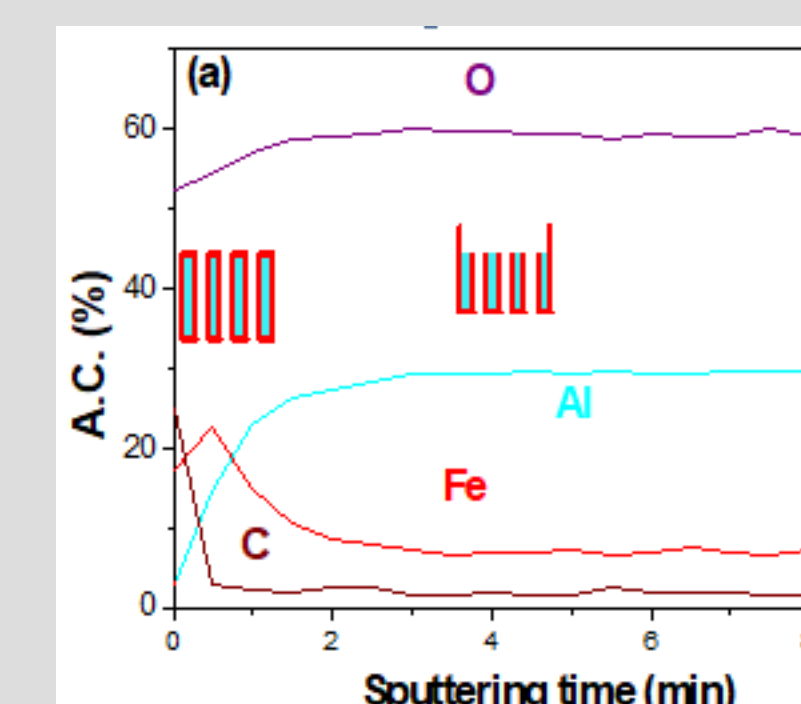
Sample	$\langle r_p \rangle$ (nm)	$\Theta$ (%)
NPAM+Al <sub>2</sub> O <sub>3</sub>	10 ± 2	9
NPAM+TiO <sub>2</sub>	10 ± 2	9
NPAM+Fe <sub>2</sub> O <sub>3</sub>	9 ± 3	8
NPAM+ZnO	9 ± 3	8

Reduction ~ 20 % respect to NPAS

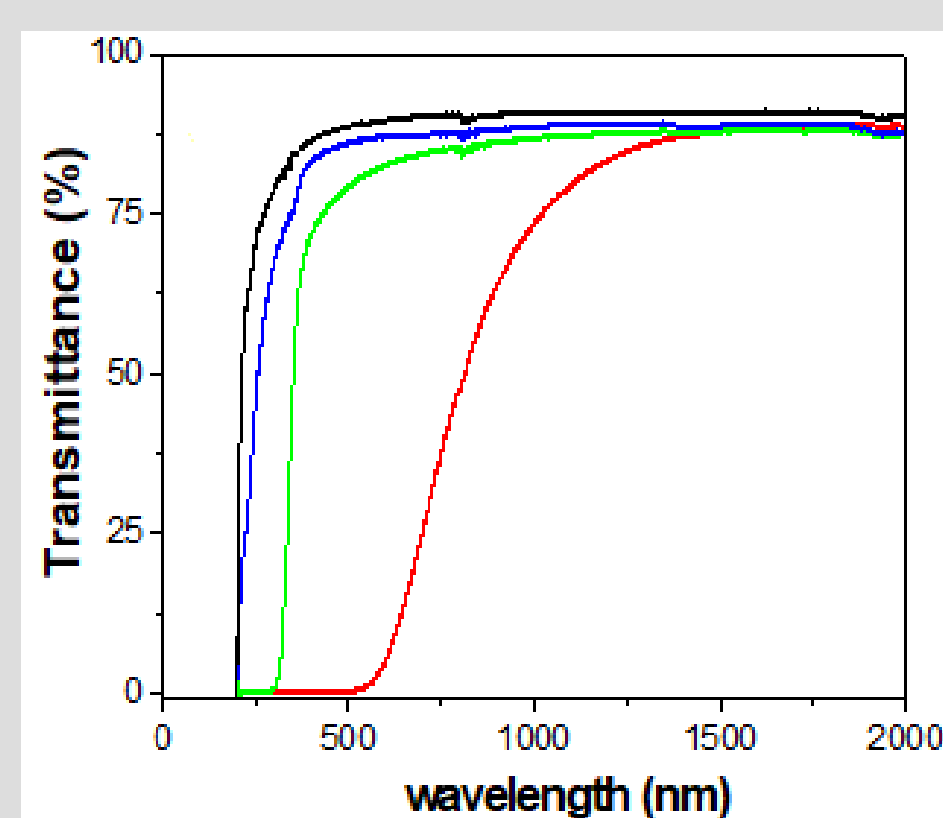
NPA-bSs surface atomic concentration % of NPA-Ss elements (other elements with A.C. % ≤ 0.5 are not indicated)

Sample	C (%)	Al (%)	O (%)	Ti (%)	Fe (%)	Zn (%)	N (%)
NPAM+Al <sub>2</sub> O <sub>3</sub>	43.6	15.7	37.7	---	---	---	2.0
NPAM+TiO <sub>2</sub>	19.2	0.6	55.5	23.5	---	---	0.7
NPAM+Fe <sub>2</sub> O <sub>3</sub>	25.9	2.1	54.6	---	16.3	---	0.5
NPAM+ZnO	43.3	8.7	37.6	---	---	10.2	0.4

Almost total coverage by TiO<sub>2</sub> or Fe<sub>2</sub>O<sub>3</sub> layers but partial for ZnO

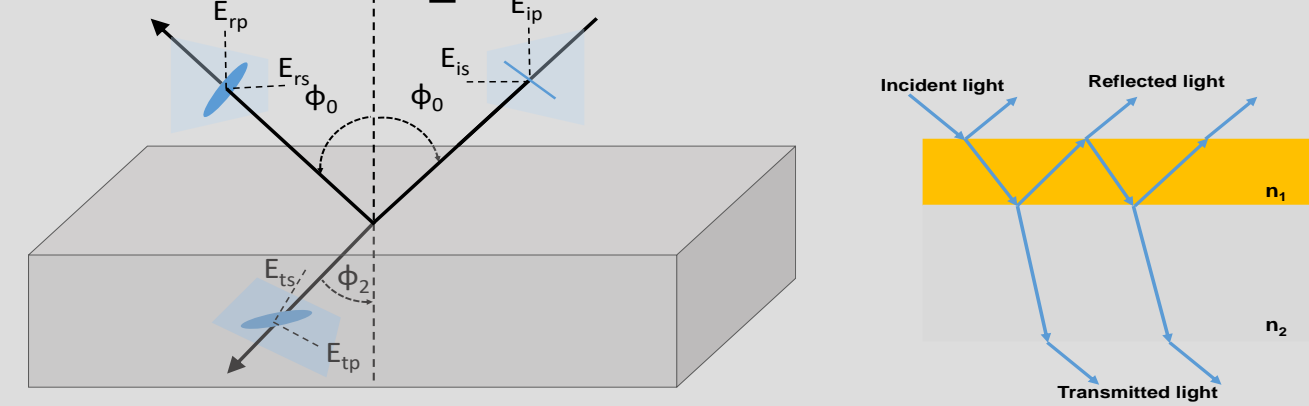


Profile curves as a function of Ar sputtering time for iron, aluminum, oxygen and carbon for NPAS+Fe<sub>2</sub>O<sub>3</sub> sample.



Sample	band gap
NPAM+Al <sub>2</sub> O <sub>3</sub>	196.5 nm
NPAM+TiO <sub>2</sub>	317.5 nm
NPAM+Fe <sub>2</sub> O <sub>3</sub>	585.1 nm
NPAM+ZnO	193.4 nm

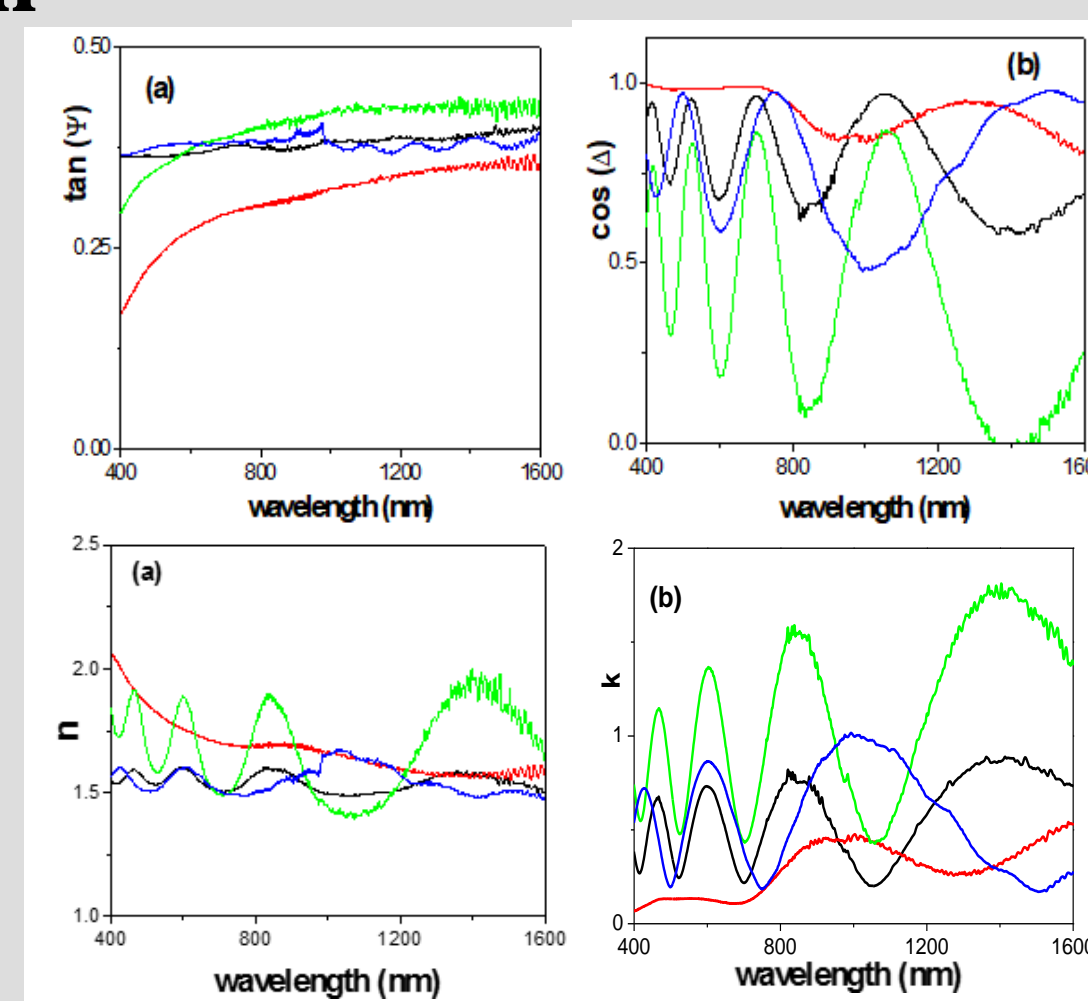
### Optical Characterization



Scheme of SE measurement for homogeneous (a) and bilayer (b) samples..

Measured  $\Psi$  and  $\Delta$  angles are related to the ratio of reflection coefficients for parallel (p) and perpendicular (s) polarized light by:

$$\rho = \frac{r_p}{r_s} = \tan \Psi e^{i\Delta}$$



Visible (vr) and near infrared (nir) average values of refractive index  $\langle n \rangle$  and extinction coefficient  $\langle k \rangle$

Sample	$\langle n_{vr} \rangle$	$\langle k_{vr} \rangle$	$\langle n_{nir} \rangle$	$\langle k_{nir} \rangle$
NPAS+Al <sub>2</sub> O <sub>3</sub>	1.55 ± 0.03	0.48 ± 0.16	1.54 ± 0.03	0.64 ± 0.22
NPAS+TiO <sub>2</sub>	1.69 ± 0.14	0.87 ± 0.29	1.69 ± 0.19	1.27 ± 0.44
NPAS+Fe <sub>2</sub> O <sub>3</sub>	1.81 ± 0.12	0.13 ± 0.04	1.62 ± 0.05	0.38 ± 0.08
NPAS+ZnO	1.54 ± 0.04	0.51 ± 0.22	1.55 ± 0.06	0.59 ± 0.29

### Conclusions:

Geometrical parameters and surface material features of a nanoporous alumina structure (NPAS) with 12 ± 2 nm pore radii and 12-15 % average porosity have been successfully modified by covering their surfaces with layers of different metal oxides (TiO<sub>2</sub>, Fe<sub>2</sub>O<sub>3</sub>, ZnO and Al<sub>2</sub>O<sub>3</sub>) by atomic layer deposition (ALD) technique, in order to get new nanoporous alumina-based structures (NPA-bSs) with modified transport and optical characteristics but similar morphology. These latter point has been confirmed by analyzing SEM images and XPS depth-profile spectra has permitted us to determine similar reduction in pore size and porosity with respect to the original support, and a cover-layer thickness of ~ 5-7 nm for the NPA-bS samples.

Coverage material affects the values of optical characteristic parameters of the NPA-bSs (band-gap, refractive index and extinction coefficient), mainly when wavelength for the visible and near-infrared regions are compared, being more significant in the case of Fe<sub>2</sub>O<sub>3</sub> coverage. For similar surface material, higher porosity/pore-size reduce refraction index and slightly affecting light transmission.

Consequently, ALD technique seems to be an adequate method for geometrical and functional changes of alumina-based nanoporous structures, opening their most common field of application (nanotemplates, drug delivery or nanomebranes) to more specific performance or platforms for biosensors or optical sensing devices.

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